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Coupling of Shear Flows in a Cylindrical Plasma Device RONGJIE HONG, Univ of California - San Diego

Spontaneous generation of parallel flows has been observed in a cylindrical plasma device. The mean parallel velocity shearing rate, V'_z , increases as the radial gradient of the plasma density, $\nabla_r n_e$, exceeds a critical value. Correspondingly, when critical density gradient is exceeded, the parallel Reynolds power, $\mathcal{P}^{\mathcal{R}|}_{\ddagger} = -\langle \sqsubseteq_{\ddagger} \rangle \nabla_{\nabla} \langle \widecheck{\cong}_{\nabla} \widecheck{\cong}_{\ddagger} \rangle$, increases substantially, indicating the mean parallel flow gains more energy from ambient turbulence. Meanwhile, the shearing rate of the mean azimuthal flow, V'_{θ} , increases with the density gradient, but soon saturates when critical density gradient is exceeded. Also, the azimuthal Reynolds power, $\mathcal{P}^{\mathcal{R}|}_{\theta} = -\langle \sqsubseteq_{\theta} \rangle \nabla_{\nabla} \langle \widecheck{\cong}_{\nabla} \fbox{\cong}_{\theta} \rangle$, drops at higher density gradient, implying that the mean azimuthal flow gains less energy from ambient turbulence. A 4-field model is employed to explain the coupling between the azimuthal flow and the parallel flow.